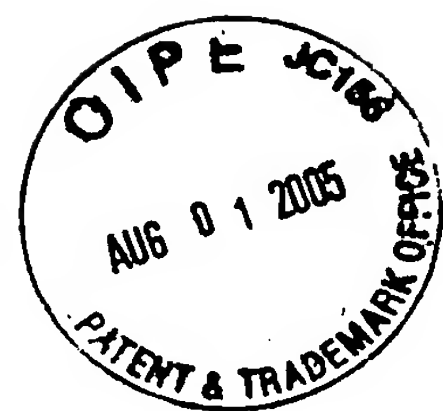


ASW



IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re application of

**Kari Härkönen, Mark Doczy,  
Teemu Lang and Nathan E. Baxter**

Confirmation No. 9896

Application No. 10/642,426

Filed: August 15, 2003

For: **DEPOSITION OF CARBON- AND  
TRANSITION METAL-CONTAINING  
THIN FILMS**

Group Art Unit: 1762

Examiner: Bret P. Chen

Date: July 29, 2005

AMENDMENT

TO THE COMMISSIONER FOR PATENTS:

In response to the March 29, 2005 Office action, please amend the above-identified patent application as follows.

**Amendments to the Specification** begin on page 2 of this paper.

**Remarks** begin on page 3 of this paper.